Robust Interaction of ZnO and TiO₂ Nanoparticles with Layered Graphitic Carbon Nitride for Enhanced Photocatalytic Oxidative Desulfurization of Fuel Oil: Mechanism, Performance and Stability

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1. Chemical

Titanium isopropoxide (TIP, 97%, Sigma-Aldrich), Zinc chloride hexahydrate (ZnCl₂.6H₂O, 98%, Sigma-Aldrich), Dibenzothiophene (C₁₂H₈S, 98%, Sigma-Aldrich), benzoquinone (p-BQ, 99%,

Sigma-Aldrich), tert-butanol (TBA, 99%, Sigma-Aldrich), potassium dichromate (K₂Cr₂O₇, 99%, Sigma-Aldrich), acetonitrile (99%, China), acetic acid (CH₃COOH, 98%, China), n-octane (98%, China), ethanol (C₂H₅OH, 98%, China), Hydrogen peroxide (H₂O₂, 30% in H₂O, China), Ammonium chloride (NH₄Cl, 98%, China).

2. Characterization techniques

Phase structure, surface valence state, elemental composition, specific surface area, morphology and optical properties of ZnO, TiO₂, OCN and 20%ZnO-TiO₂/OCN material samples analyzed by X-ray diffraction (XRD, D8 ADVANCE, Bruker, Germany), X-ray photoelectron spectroscopy (XPS, Thermo VG Multilab 2000), Energy Dispersive X-ray Spectroscopy (EDS, JED-2300), transmission electron microscopy (TEM, Leica IEO 906E), photoluminescence (PL, Varian), Mott-Schottky (MS, Biologic SP 300), electrochemical impedance spectroscopy (EIS, AUTOLAB, Metrohm, Netherland), gas chromatography–mass spectrometry (GC-MS, ISQ 7000 GC-MS system by Thermo Scientific), and UV-Vis diffuse reflectance spectra (UV-Vis DRS, UV-2600, Shimadzu) methods.

The product of the oxidative desulfurization process is determined on the ISQ 7000 GC-MS system by Thermo Scientific. The system includes Trace 1310 gas chromatography, ISO 7000 ExtractaBrite ion source mass spectrometer, Lumin gas purifier and trap, CombiPAL CTC Analytics AG automatic sample injector with headspace sampling, and TraceGOLD TG-5MS chromatography column by Thermo Scientific: column height 30 m, inner diameter 0.25 mm, stationary phase thickness 0.25 μ m.

First, 1 mL of the sample is placed in a 1.8 mL vial and heated to 250 °C. The gas chromatography column is heated to 50 °C for 1 minute; then heated from 50 °C to 100 °C and held for 2 minutes; then heated to 270 °C and held for 20 minutes, and finally heated to 300 °C. The gas chromatography column heating process is performed at a rate of 50 °C/minute. Then, helium gas is used at a rate of 1 mL/minute to transfer the product from the GC to the open MS at 280 °C. The ion source temperature is 250 °C, and the ionization mode is electron impact (EI). The product of the oxidative desulfurization process is processed using the Chromeleon[™] chromatography data system (CDS) software.

3. Additional information and results

Table S1. The content of $ZnCl_2.6H_2O$ and titanium isopropoxide used in the synthesis of $ZnO-TiO_2/OCN$ samples

Samples	OCN	Titanium(IV)	ZnCl ₂ .6H ₂ O
	(g)	Isopropoxide (mL)	(g)
10%ZnO-TiO ₂ /OCN	0.5	1.52	0.30
20%ZnO-TiO ₂ /OCN	0.5	1.14	0.60
30%ZnO-TiO ₂ /OCN	0.5	0.76	0.91

Table S2. Binding energies of the bonds in the ZnO, TiO₂, OCN and 20%ZnO-TiO₂/OCN samples

		ZnO	TiO ₂	OCN	20%ZnO-	20%ZnO-TiO ₂ /OCN
					TiO ₂ /OCN	after 5 cycles
Zn2p	Zn 2p _{1/2}	1022.60	-	-	1022.72	1022.81
	Zn 2p _{3/2}	1045.75	-	-	1045.81	1022.83
	Ti ³⁺	-	-	-	457.47	458.64
Ti2n		-	-	-	462.96	463.17
112p	Ti ⁴⁺	-	458.52	-	458.79	459.72
		-	464.17	-	464.46	465.53
	Ti-N	-	-	-	460.28	461.36
		-	-	-	465.91	466.77
	sp ² C–C	-	-	284.87	284.73	284.85
C1s	C–O	-	-	287.80	287.51	287.59
	N–C=N	-	-	288.53	288.03	288.37
	Ti- N	-	-	-	396.63	396.81

N1s	C-N=C	-	-	398.77	398.59	398.80
	sp ³ N	-	-	400.41	399.92	400.00
	C ₂ –NH	-	-	401.74	401.31	401.43
	N–C–O	-	-	530.64	530.48	530.99
O1s	Ti-O or Zn-O	532.09	532.00	-	532.29	532.77
	-OH groups	533.91	533.88	533.93	533.97	534.55

Table S3. Element composition (wt%) of OCN and ZnO-TiO₂/OCN samples

Samples	С	Ν	0	Ti	Zn	Total
OCN	43.60	51.66	4.74	-	-	100
10%ZnO-TiO ₂ /OCN	22.04	26.12	20.34	23.63	7.87	100
20%ZnO-TiO ₂ /OCN	21.94	26.07	18.69	16.94	16.36	100
30%ZnO-TiO ₂ /OCN	21.92	26.47	15.18	12.9	23.53	100

Table S4. The benchmark of the as-synthesized $20\% ZnO\textsc{-}TiO_2/OCN$ sample

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Materials	Reaction conditions	Light source	Photocatalytic Ref.
			performance
ZnO/FSM-16	$[DBT] = 200 \text{ mg } L^{-1}$	Hg lamp (60 W,	95% in 550 min [1]
	$m_{catalyst}\!=\!0.3~g~L^{-1}$	UV)	
TiO_2/g - C_3N_4	$[DBT] = 500 \text{ mg } L^{-1}$	250 W high-	98.9% in 120 [2]
	$m_{catalyst}{=}10.0~g~L^{-1}$	pressure Hg	min
		lamp (UV light)	
Ti_3C_2/g - C_3N_4	$[TH] = 140 \text{ mg } L^{-1}$	300 W xenon	73.6% in [3]
	$m_{catalyst} = 2.5 \text{ g L } \text{L}^{-1}$	lamp	180 min
Ag@AgBr/Al-SBA-15	$[DBT] = 500 \text{ mg } L^{-1}$	Sunlight	98.66% in 300 [4]
	$m_{catalyst} = 1.0 \text{ g L}^{-1}$	irradiation	min
Ti-SBA-15	$[DBT] = 500 \text{ mg } L^{-1}$	35 W UV light	92.68% in 360 [5]
	$m_{catalyst} = 2.5 \text{ g L}^{-1}$		min

Ag_3PO_4/d - C_3N_4	$[DBT] = 200 \text{ mg } L^{-1}$	300 W xenon	92.5% in 180 [6]
	$m_{catalyst}{=}2.5~g~L^{-1}$	lamp	min
AgCl/PbMoO ₄	$[DBT] = 200 \text{ mg } L^{-1}$	Not mentioned	97.0% in 120 [7]
	$m_{catalyst} = 1.5 \text{ g } \text{L}^{-1}$		min
Ni-WO ₃ @g-C ₃ N ₄	$[DBT] = 100 \text{ mg } L^{-1}$	Not mentioned	97.0% in 180 [8]
	$m_{catalyst}{=}2.0~g~L^{-1}$		min
$WO_3/g-C_3N_4$	$[DBT] = 500 \text{ mg } L^{-1}$ Not mentioned		91.2% in 180 [9]
	$m_{catalyst}{=}2.0~g~L^{-1}$		min
$CeO_2/ATP/g-C_3N_4$	$[DBT] = 200 \text{ mg } L^{-1}$	300 W xenon	98 % in [10]
		lamp	180 min
ZnO-TiO ₂ /OCN	$[DBT] = 300 \text{ mg } L^{-1}$	300 W xenon	99.19% in 120 This work
	$m_{catalyst} = 1.5 \text{ g } \text{L}^{-1}$	lamp	min

Table S5. Calculated optical properties of the (TiO₂)₇, (ZnO)₆, (TiO₂)₇(ZnO)₆, OCN and ZnO-TiO₂/OCN samples

System	(TiO ₂) ₇	(ZnO) ₆	$(TiO_2)_7(ZnO)_6$	OCN	ZnO-TiO ₂ /OCN
Bandgap (eV)	5.00	4.28	3.97	4.17	3.44
Peak (UV, eV)	3.89	3.26	3.27	3.66	2.83



20%ZnO-TiO₂/OCN

Figure S1. Schematic synthesis of ZnO-TiO₂/OCN materials by microwave-assisted sol-gel method





Figure S2. Survey XPS spectra of ZnO (A), TiO_2 (B), OCN (C) and 20%ZnO-TiO₂/OCN (D) samples



Figure S3. EDS spectrum (A), EDS element layered image (B), EDS element mapping images of C (C), N (D) and O (E) of OCN sample.



Figure S4. HRTEM image of 20%ZnO-TiO₂/OCN sample



Figure S5. Mott–Schottky (MS) plot of ZnO, TiO2 and OCN samples



Figure S6. DBT conversion using ZnO/OCN, TiO₂/OCN, ZnO-TiO₂ and ZnO-TiO₂/OCN samples



Figure S7. First-order reaction kinetics of ZnO/OCN, TiO₂/OCN, ZnO-TiO₂, and ZnO-TiO₂/OCN samples







Figure S8. GC-MS of DBT (A) GC-MS spectra of the products in the desulfurization of DBT over 20%ZnO-TiO₂/OCN photocatalyst after 20 min (B) and 120 min (C)



Figure S9. ESR spectra of 20%ZnO-TiO₂/OCN in the presence DMPO to detect 'OH and 'O₂⁻.



Figure S10. XRD patterns of 20%ZnO-TiO₂/OCN sample before and after reaction



Figure S11. TEM image of 20%ZnO-TiO₂/OCN sample before and after the reaction.

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